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Advanced Control and Learning in Manufacturing

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closed (30 September 2021)

Message from the Guest Editor

Dear Colleagues,

We would like to draw your attention to this Special Issue of *JMMP* on "Advanced Control and Learning in Manufacturing".

The future of manufacturing is shaped by integrating data-driven insights and approaches throughout the manufacturing process chain. The available sensor data collected at multiple stages enable new data-driven or learning-based methods in automation, optimization, and control of industrial manufacturing systems. This new data-based intelligence opens up new possibilities for scaling of the production processes, and new operational models, based on individualized or streamlined production.

This Special Issue on "Control and Learning in Manufacturing" focuses on contributions that detail new developments and enhance the understanding and integration of data-driven approaches to manufacturing applications.

For more information, please clink: https://www.mdpi.com/si/65656.











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Message from the Editor-in-Chief

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